WORLD’S MOST ADVANCED
PATTERNED DIAMOND TECHNOLOGY

ZENESIS®

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ZENESIS® TECHNOLOGY

ZENESIS® is a platform technology that brings to life dramatic improvement in diamond tool performance by its ability to custom design and mass produce optimal patterns of diamonds based on application needs.

ZENESIS® New Edition

A New Revolutionary Platform of Diamond Tools

- **NEW PLATFORM**
  - Ideally-analyzed diamond positions create the new platform of pattern structures.
  - Remarkable progress in the technique of multi-complex layers from previous version.

- **DESIGNED PERFORMANCE**
  - Matching platform with applications maximizes sawing performance for specific uses.
  - Consistent wear behavior in even extreme sawing conditions.

- **PRECISION MANUFACTURING**
  - Most sophisticated manufacturing process enhances the product’s stability and its perfection.
  - Highly-utilized production process allows greater flexibility and productivity.

ADVANCED ISOSCELES TRIANGULAR STRUCTURE

- **Design**: Advanced isosceles triangular structure.
- **Concept**: Platform that consists of an advanced triangular structure is designed to control a time of diamond exposure for unlimited innovation.
- **Effect**: Trouble-free sawing and drilling on even the most difficult jobs.

MULTI-DESIGNED LAYERS

- **Design**: Multi-designed layers.
- **Concept**: Multi-designed layers are patterned to control a portion of diamond exposure and number of diamond on the cut for stable wear and optimized sawing performance.
- **Effect**: Consistent and stable performance on various applications.